Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S94	38004	@ad<"20030326" and ((enlarg\$3 increas\$3 big\$4 add\$3 boost\$3 expand\$3 extend\$3 larger) with pattern) and (mask photomask (photo adj mask) reticle)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 10:30
S95	5835	@ad<"20030326" and ((enlarg\$3 increas\$3 big\$4 add\$3 boost\$3 expand\$3 extend\$3 larger resiz\$3 ("re" adj (size sizing))) with pattern) and ((mask photomask (photo adj mask) reticle) with (data informat\$3))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 10:33
S96	2635	@ad<"20030326" and ((enlarg\$3 increas\$3 big\$4 add\$3 boost\$3 expand\$3 extend\$3 larger resiz\$3 ("re" adj (size sizing))) with pattern) and ((mask photomask (photo adj mask) reticle) with (data informat\$3)) and (photolithograph\$3 (photo adj lithograph\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 10:34
S97	640	@ad<"20030326" and ((enlarg\$3 increas\$3 big\$4 add\$3 boost\$3 expand\$3 extend\$3 larger resiz\$3 ("re" adj (size sizing))) with (pattern feature)) and ((mask photomask (photo adj mask) reticle) with (data informat\$3 rules parameter\$3 criteria specification)) and (photolithograph\$3 (photo adj lithograph\$3) lithograph\$3 exposur\$3) and ((second another different trim\$4 secondary subsequent modif\$7) with (\$5mask (photo adj (mask reticle)) reticle) with (correspond\$5 align\$5 equivalen\$3 complementary matching) with (\$5mask (photo adj (mask reticle)) reticle)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 11:01

S98	144	@ad<"20030326" and ((enlarg\$3 increas\$3 big\$4 add\$3 boost\$3 expand\$3 extend\$3 larger resiz\$3 ("re" adj (size sizing))) with (pattern feature)) and ((mask photomask (photo adj mask) reticle) with (data informat\$3 rules parameter\$3 criteria specification)) and (photolithograph\$3 (photo adj lithograph\$3) lithograph\$3 exposur\$3) and ((second another different trim\$4 secondary subsequent modif\$7) with (\$5mask (photo adj (mask reticle)) reticle) with (correspond\$5 align\$5 equivalen\$3 complementary matching) with ((first initial primary orginial) with (\$5mask (photo adj (mask reticle)) reticle))) and ((minimum min minimal least small\$3) with (line conductor trace wire wiring) with width)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 11:04
S10 1	155	(((enlarg\$3 increas\$3 augment\$5 amplify\$8 magnif\$8) near5 (lin\$3 margin cd (critical near3 (dimension measurement features)) thin fine width\$3 spac\$3 densit\$3 feature)) and ((proximity near5 (effect\$3 correct\$4)) or ope or ppc) and ((opc (optical with (correct\$3 effect\$3))) and ((first primary initial) near4 (photomask (photo adj (mask reticle)) mask reticle)) and (((second trim\$4 (multi adj phase near transistion)) near4 mask)) and ((reduc\$5 decreas\$3 shrink\$3 diminish\$3 lessen\$3 truncat\$5 cutback) with (width pitch densit\$3 spac\$3 cd (critical near3 (dimension\$3 measurement feature)))) and @ad<"20030326"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 14:34

S10 0	152	@ad<"20030326" and ((enlarg\$3 increas\$3 big\$4 add\$3 boost\$3 expand\$3 extend\$3 larger (enhanc\$5	US-PGPUB; USPAT; USOCR; FPRS;	OR	ON	2007/05/09 14:34
	·	near5 (size dimension area)) resiz\$3 ("re" adj (size sizing))) with (pattern feature)) and ((mask photomask (photo adj mask) reticle) with (data informat\$3 rules parameter\$3 criteria specification)) and ((second another different trim\$4 secondary subsequent modif\$7) with (\$5mask (photo adj (mask reticle)) reticle) with (correspond\$5 align\$5 equivalen\$3 complementary matching) with ((first initial primary orginial) with (\$5mask (photo adj (mask reticle)) reticle))) and ((minimum min minimal least small\$3) with (line conductor trace wire wiring) with width)	EPO; JPO; DERWENT; IBM_TDB			
S10 2	1	@ad<"20030326" and ((enlarg\$3 increas\$3 big\$4 add\$3 boost\$3 expand\$3 extend\$3 larger (enhanc\$5 near5 (size dimension area)) resiz\$3 ("re" adj (size sizing))) with (pattern feature)) and ((mask photomask (photo adj mask) reticle) with (data)) and ((second another different trim\$4 secondary subsequent modif\$7) with (\$5mask (photo adj (mask reticle)) reticle) with (correspond\$5 align\$5 equivalen\$3 complementary matching) with ((first initial primary orginial) with (\$5mask (photo adj (mask reticle)) reticle))) and (space with (area portion region)) and ((resizing ("re" adj (size sizing))) with (quantit\$3 number value digit amount))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 14:47
S10 3		(pattern and enlarg\$3 and space and mask and data and width and (resize resizing ("re" adj (size sizing)))).clm.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 15:08
S1	528	(prepar\$3 produc\$3 construc\$4 develop\$5 provid\$4 forming formation form generat\$3 build\$3 contriv\$3 fabricat\$5 creat\$3) with mask with data with transfer	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/12 13:08

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S99	144	@ad<"20030326" and ((enlarg\$3 increas\$3 big\$4 add\$3 boost\$3 expand\$3 extend\$3 larger (enhanc\$5 near5 (size dimension area)) resiz\$3 ("re" adj (size sizing))) with (pattern feature)) and ((mask photomask (photo adj mask) reticle) with (data informat\$3 rules parameter\$3 criteria specification)) and (photolithograph\$3 (photo adj lithograph\$3) lithograph\$3 exposur\$3) and ((second another different trim\$4 secondary subsequent modif\$7) with (\$5mask (photo adj (mask reticle)) reticle) with (correspond\$5 align\$5 equivalen\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/12 13:09
		complementary matching) with ((first initial primary orginial) with (\$5mask (photo adj (mask reticle)) reticle))) and ((minimum min minimal least small\$3) with (line conductor trace wire wiring) with width)				
L1	278	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) and (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) and transfer\$4 with (pattern\$3 substrate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:23
L4	1	l1 and "716"/\$2.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:26
L5	5	@ad<"20030326" and (((enlarge\$4 grow\$3 stretch\$3) with pattern) same (minimum minimal min) with (space spacing)) and (((enlarge\$4 grow\$3 stretch\$3) with pattern) same (align\$5 overlay\$3 (over adj lay\$3)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:32
S10 4	17	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:33

L6	0	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal min) with (space spacing))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:34
L9	51	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) and (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing width))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:35
L8	15	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) and (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:35
L7	. 0	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:35
L10	. 3	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing width))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:43
L11	3	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing width)) and (reduc\$5 shrink\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:44

L12	1	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing width)) and (reduc\$5 shrink\$3) and (opc (optical with proximit\$3 with correct\$3))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 09:45
L13	3	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing width)) and (reduc\$5 shrink\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 10:22
L15	11	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) and (align\$5 overlay\$3 (over adj lay\$3))) and (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing width)) and (fine with (width space spacing))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 10:26
L14	2	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) and (align\$5 overlay\$3 (over adj lay\$3))) and (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate) and ((minimum minimal "min") with (space spacing width)) and (opc (optical with proximit\$3 with (correct\$3 effect\$3)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 10:26
L16	17	@ad<"20030326" and ((mask photomask (photo adj mask) reticle) with (align\$5 overlay\$3 (over adj lay\$3))) with (enlarg\$5 grow\$3 stretch\$3) with transfer\$4 with (pattern\$3 substrate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 10:48
L17	255	@ad<"20030326" and ((minimum minimal min) with (space spacing width)) and ((enlarge\$4 grow\$3 stretch\$3) with (pattern mask photomask (photo adj mask))) and (align\$5 overlay\$3 (over adj lay\$3)) and (mask with set)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 10:49

L19	18	@ad<"20030326" and ((minimum minimal min) with (space spacing	US-PGPUB; USPAT;	OR	ON	2007/05/13 10:50
		width)) and ((enlarge\$4 grow\$3 stretch\$3) with (pattern mask photomask (photo adj mask))) and (align\$5 overlay\$3 (over adj lay\$3)) same (mask with set) and ((select\$3 with expos\$5))	USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB			
L18	91	@ad<"20030326" and ((minimum minimal min) with (space spacing width)) and ((enlarge\$4 grow\$3 stretch\$3) with (pattern mask photomask (photo adj mask))) and (align\$5 overlay\$3 (over adj lay\$3)) and (mask with set) and ((select\$3 with expos\$5))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 10:50
L20	19	@ad<"20030326" and ((minimum minimal min) with (space spacing width)) and ((enlarge\$4 grow\$3 stretch\$3) with (pattern mask photomask (photo adj mask))) and (align\$5 overlay\$3 (over adj lay\$3)) same ((mask mask photomask (photo adj mask)) with set) and ((select\$3 with expos\$5))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 10:54
L21	28	@ad<"20030326" and ((minimum minimal min) with (space spacing width)) and ((enlarge\$4 grow\$3 stretch\$3) with (pattern mask photomask (photo adj mask))) and (align\$5 overlay\$3 (over adj lay\$3)) same ((select\$5 with expos\$5)) and ((mask mask photomask (photo adj mask)) with set)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 11:22
L22	58	@ad<"20030326" and ((minimum minimal min) with (space spacing width)) and ((enlarge\$4 grow\$3 stretch\$3) with (pattern mask photomask (photo adj mask))) and (align\$5 overlay\$3 (over adj lay\$3)) same ((select\$5 with expos\$5) with (pattern \$5mask reticle (photo adj mask) substrate))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 11:23
L23	58	@ad<"20030326" and ((minimum minimal min) with (space spacing width)) and ((enlarge\$4 grow\$3 stretch\$3) with (pattern mask reticle photomask (photo adj mask))) and (align\$5 overlay\$3 (over adj lay\$3)) same ((select\$5 with expos\$5) with (pattern \$5mask reticle (photo adj mask) substrate))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 11:35

L31	432	@ad<"20030326" and (opc with (purpose benefit advantag\$4))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 12:21
L33	440	@ad<"20030326" and (opc with known)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 12:22
L32	149	@ad<"20030326" and (opc with (purpose))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/13 12:22
L34	123	@ad<"20030326" and ((optical with proximit\$3 with correct\$3) with known)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM TDB	OR	ON	2007/05/13 12:45